

What is claimed is:

1. A method for manufacturing a crystal plate, comprising the steps of:  
adhering one of an amorphous plate and a crystalline body integrally  
5 and merging with the amorphous plate and the crystalline body; and  
separating the amorphous plate from the crystalline body after the  
crystal structure of the crystalline body is copied to the amorphous plate.

2. A method for manufacturing a crystal plate, comprising the steps of:  
10 treating a surface of an amorphous plate and a crystalline body;  
adhering the amorphous plate and the crystalline body one of inside or  
outside of an adjustable kiln which applies and uses the combination of light,  
heat, electricity after the treating step is performed;  
processing so as to copy a crystal structure of the crystalline body to the  
15 amorphous plate after the adjustable kiln is worked; and  
separating the amorphous plate from the crystalline body.

3. The method of claim 2 wherein the step of processing includes that  
the amorphous plate with an unstable state is attracted, and the adjustable  
20 kiln works and heated at approximately 500 to 3000 °C.

4. The method of any one of claims 1 and 2 wherein the step of separating  
includes that the amorphous plate and crystalline body are pressed after the  
processing step is performed

5. The method of any one of claims 1 and 2 wherein the step of separating includes that the amorphous plate and crystalline body are vibrated with one of a wave motion and an oscillating equipment after the processing step is performed.

6. The method of any one of claims 1 and 2 wherein the step of separating includes that the amorphous plate and crystalline body are collided suitably after the processing step is performed.

7. The method of any one of claims 1 and 2 wherein the step of separating includes that the amorphous plate and crystalline body are irradiated one of an ultraviolet ray, infrared rays and visible light suitably after the processing step is performed.